



Cite this: *RSC Adv.*, 2019, 9, 5987

# Pd-loaded SnO<sub>2</sub> hierarchical nanospheres for a high dynamic range H<sub>2</sub>S micro sensor†

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Herein, a high dynamic range H<sub>2</sub>S micro gas sensor was achieved using hierarchical Pd-loaded SnO<sub>2</sub> nanostructures as a sensing material. SnO<sub>2</sub> nanospheres were synthesized using a hydrothermal method without any surfactants or templates, followed by Pd nanoparticle decoration *via* a facile method. A hierarchical nanostructure of Pd-loaded SnO<sub>2</sub> was formed, and its sensing abilities were compared with those of pure SnO<sub>2</sub> nanosphere-based sensors. The Pd-loaded SnO<sub>2</sub> hierarchical nanostructures showed an ultra-sensitive H<sub>2</sub>S detection ability down to 10 ppb, a high dynamic range (4 orders of magnitude) up to 200 ppm, and a low working temperature (150 °C). Thus, this micro gas sensor based on Pd-loaded SnO<sub>2</sub> hierarchical nanostructures has promising applications in universal H<sub>2</sub>S detection. The fabrication method presented herein is simple, renewable and operable and thus may be extended to synthesize other types of metal oxide-based semiconductor micro sensors for application in various fields.

Received 5th November 2018  
 Accepted 1st February 2019

DOI: 10.1039/c8ra09156k

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## 1. Introduction

In the chemical industry, safety risk because of toxic gases is an important issue; therefore, the demand for the detection and monitoring of toxic gases is very high. Among dangerous gases, hydrogen sulphide (H<sub>2</sub>S) is a common toxic, colorless gas pollutant. Although the occupational exposure limit for H<sub>2</sub>S is 10 ppm for 8 h exposure, the acceptable ambient concentration of H<sub>2</sub>S (recommended by the Scientific Advisory Board on Toxic Air Pollutants USA) is under 20–100 ppb.<sup>1</sup> Thus, the detection of H<sub>2</sub>S at the ppb level is crucial. Moreover, H<sub>2</sub>S is a corrosive gas, and at high concentrations, H<sub>2</sub>S can damage the sensor. Thus, the achievement of a large dynamic range sensor is difficult.

Semiconductor sensors are widely studied and used, which mainly consist of metal-oxide semiconductors (MOSS).<sup>2–4</sup>

Compared with other types of sensors, they have a fast response, wide gas response concentration range, low cost, easy operation and portability. Common sensitive metal-oxide semiconductors are SnO<sub>2</sub>,<sup>5–7</sup> ZnO,<sup>8,9</sup> Fe<sub>2</sub>O<sub>3</sub>,<sup>10,11</sup> WO<sub>3</sub> (ref. 12 and 13) and In<sub>2</sub>O<sub>3</sub>.<sup>14,15</sup> When exposed to the target gas, these oxides respond with resistive changes and are suitable for sensing. SnO<sub>2</sub>, ZnO and Fe<sub>2</sub>O<sub>3</sub> have a good gas sensing property for reducing gases and combustible gases, whereas WO<sub>3</sub> and In<sub>2</sub>O<sub>3</sub> show good sensing property for oxidizing gases. Tin oxide (SnO<sub>2</sub>) is one of the typical n-type metal-oxide semiconductors with a wide band gap ( $E_g = 3.6$  eV at 300 K). Due to their large surface-to-volume ratios, nanostructured SnO<sub>2</sub>, including nanoparticles, nanowires and thin films,<sup>16–19</sup> have been developed to achieve enhanced sensing capabilities.<sup>20</sup> Using a nanostructure with a large surface-to-volume ratio, the SnO<sub>2</sub> gas sensors showed improved resistive responses when exposed to target gases.<sup>20–22</sup> Further improvement, such as in terms of the detection range and selectivity, of the gas sensing performance was achieved *via* surface loading of noble metals,<sup>23–27</sup> for example Au,<sup>28,29</sup> Ag,<sup>20,30,31</sup> Pd<sup>32,33</sup> and Pt.<sup>34,35</sup> Compared with other metals, palladium (Pd) has a low binding energy, and the low barriers for hydrogen dissociation and oxygen adsorption reduce the activation energy; thus, it can affect the conductivity and gas response of the sensitive membrane of the sensor.

In this study, we developed an ultra-sensitive H<sub>2</sub>S micro gas sensor with 2% Pd-loaded SnO<sub>2</sub> hierarchical nanostructures based on pure SnO<sub>2</sub> nanospheres, fabricated by hydrothermal and micro-nano processing technology. The micro gas sensor used interdigital Cr/Au electrodes (300 μm × 300 μm) coated with the Pd-loaded SnO<sub>2</sub> nanostructures. Micro gas sensors have low cost, low energy consumption and ability of sensor

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† Electronic supplementary information (ESI) available. See DOI: 10.1039/c8ra09156k



array integration. The gas sensing ability was tested in ambient air using a precise electrical meter to measure the gas response capabilities. For comparison, a pure SnO<sub>2</sub> nanosphere sensing film was deposited on a micro sensing chip. We demonstrated that Pd-loaded SnO<sub>2</sub> had a hierarchical nanostructure as compared to the pure SnO<sub>2</sub> nanospheres and showed a high gas response (5 ppm/27.6), an ultra-sensitive detection limit, a wide detection range (10 ppb to 200 ppm) and a low operating temperature (down to 150 °C).

## 2. Experimental

### 2.1 Preparation of the Pd-loaded SnO<sub>2</sub> nanospheres

SnCl<sub>2</sub>·2H<sub>2</sub>O (0.45 g), oxalic acid (0.8 g), hydrazine hydrate (5.856 g), and hydrochloric acid (0.08 mL) were dissolved in deionized water (37.8 mL) to form a clear and colorless mixture solution. After being stirred for 30 min, the solution was put in a 40 mL Teflon liner followed by heating to 180 °C for 24 h. The resulting product was washed with double distilled water and further dried at 60 °C in air to obtain the SnO<sub>2</sub> powder. Subsequently, the SnO<sub>2</sub> powder was heated to 600 °C at the ramping rate of 5 °C min<sup>-1</sup> in a tube furnace under flowing air, and the temperature was maintained at 600 °C for 2 h.

The Pd-loaded SnO<sub>2</sub> nanospheres were synthesized by solvent evaporation as follows: 100 mg SnO<sub>2</sub> powder was suspended in 1 mL ethanol under stirring. Moreover, 1 mL PdCl<sub>2</sub> (2 wt%, where wt% is the mean of weight percent) was added and dissolved in the obtained solution. After stirring for 10 min, the solution was transferred to a centrifuge tube to evaporate the solvent at 80 °C in a water bath until the solvent was completely removed. The final products were obtained and subsequently annealed at 500 °C for 1 h at the heating rate of 5 °C min<sup>-1</sup> in air.

All reagents and materials used in the present experiment were of analytical grade and applied without further purification. Double-distilled water was used throughout all the experiments.

### 2.2 Material characterization

The crystal structure of our samples was characterized using Bruker D8 XRD with Cu-K $\alpha$  radiation ( $\lambda = 1.5419 \text{ \AA}$ ) at room temperature. The morphology of the final products was investigated using scanning electron microscopy (SEM, Carl Zeiss, ZEISS SIGMA). Transmission electron microscopy (TEM) and high-resolution transmission electron microscopy (HRTEM) analysis were performed using JEOL-2010 at the accelerating voltage of 200 kV.

### 2.3 Fabrication of micro gas sensors and measurement of the gas-sensing performance

Our micro gas sensors were composed of 300  $\mu\text{m}$  sized interdigitated gold electrodes covered with Pd-loaded SnO<sub>2</sub> nanospheres as well as pure SnO<sub>2</sub> nanospheres for comparison. The interdigitated electrodes were fabricated on silicon dioxide (SiO<sub>2</sub>) with a thickness of about 300 nm by photolithography, followed by deposition with Cr/Au (5/100 nm) by thermal

evaporation. The vacuum value during evaporation was under  $5 \times 10^{-7}$  mbar. The deposition rate of Cr and Au was  $0.1 \text{ \AA s}^{-1}$  and  $1 \text{ \AA s}^{-1}$ , respectively. The interdigitated electrode spacing was 30  $\mu\text{m}$ , and the electrode width was 15  $\mu\text{m}$ . Finally, the sensor chips were placed in acetone for 5–6 h, and the unwanted metal was removed.

The as-prepared Pd-loaded SnO<sub>2</sub> nanospheres were dispersed in terpineol at the mass ratio of 8 : 5 to form a paste. After grinding for 10 min, the obtained paste was transferred to the SiO<sub>2</sub>/Si substrate with an interdigitated electrode, followed by drying at 40 °C for 12 h to remove the solvent. The obtained sensor film was annealed at 300 °C for 20 min before measurement to further improve the response and stability. Finally, the chip was fixed in a chip carrier with silver paste and wire bonded using a Si/Al wire.

The gas-sensing measurement was performed using H<sub>2</sub>S with concentration ranging from 10 ppb to 200 ppm at the operation temperature of 150–350 °C. After the micro sensor was heated to the target temperature and its resistance was stabilized, a calculated volume of the gas was injected into the test chamber (2 liters) using a micro-injector. As is known, relative humidity can play an important role in the gas sensing performance.<sup>36,37</sup> Therefore, we carefully monitored the relative humidity in our test environment. All measurements in this study were conducted at about  $30 \pm 5\%$  relative humidity and at a room temperature of  $25 \pm 5 \text{ }^\circ\text{C}$ . The gas response was calculated based on the equation  $S = (R_{\text{air}} - R_{\text{gas}})/R_{\text{gas}}$ , where  $R_{\text{air}}$  is the resistance of the sensor in air and  $R_{\text{gas}}$  is the resistance of the sensor exposed to the target gas environment.

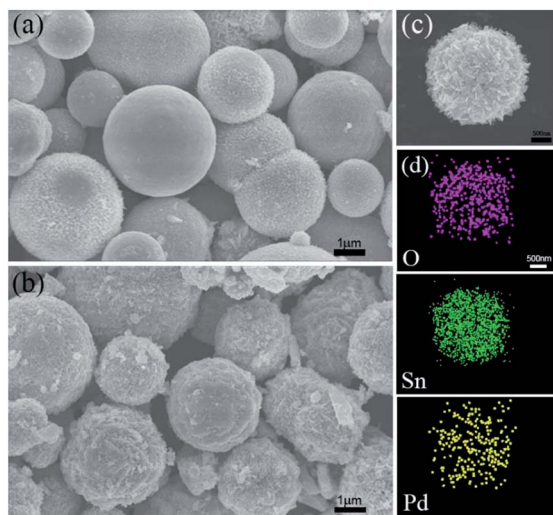
## 3. Results and discussion

### 3.1 Structure and morphology

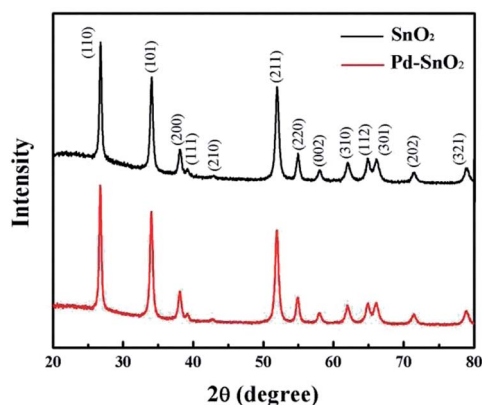
The morphology and structure of the pure SnO<sub>2</sub> nanosphere particles and Pd-loaded SnO<sub>2</sub> nanosphere particles were characterized *via* SEM, TEM and XRD. Fig. 1 shows the SEM images of both samples. The pure SnO<sub>2</sub> nanospheres have a smooth surface, and their diameter is about 1  $\mu\text{m}$  (Fig. 1a). On the other hand, the Pd-modified SnO<sub>2</sub> nanospheres show a rough surface and fine nanostructures. Their surface area increased after Pd loading; however, the overall size remained unchanged (Fig. 1b and c). A layered structure could be seen, and the nanosheets protruded out of the sphere. An increase in the surface area results in more active sites for target gas sensing, and more contact sites *via* the nanosheets between adjacent nanospheres will enhance the sensitivities. Elementary mapping by EDX (Fig. 1d) shows that the distribution and formation of O, Sn, and Pd elements are uniform on the nanosphere surface. This confirms that Pd ions have been successfully loaded on the SnO<sub>2</sub> surface.

XRD analysis was used to determine the phase structures of the as-prepared pure SnO<sub>2</sub> and Pd-loaded SnO<sub>2</sub> powders. The XRD pattern of both the SnO<sub>2</sub> and Pd-loaded SnO<sub>2</sub> nanosphere structures reflect the monoclinic structure of SnO<sub>2</sub> [JCPDS card, no. 41-1445, space group:  $P4_2/mnm$  (136)], which was confirmed by HRTEM in Fig. 2. In these two spectra, there are no obvious characteristic peaks of Pd species mainly due to the low amount





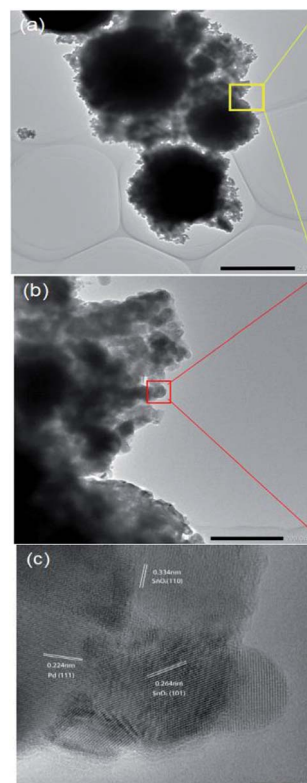
**Fig. 1** SEM images of the (a) pure SnO<sub>2</sub> nanosphere structures, (b) Pd-loaded SnO<sub>2</sub> nanosphere structures, and (c) single Pd-loaded SnO<sub>2</sub> nanosphere structures, and (d) SEM-EDX elemental mapping images of (c) single Pd-loaded SnO<sub>2</sub> nanosphere structure.



**Fig. 2** XRD patterns of the pure SnO<sub>2</sub> nanosphere structures (top) and the Pd-loaded SnO<sub>2</sub> nanosphere structures (bottom).

of Pd and extremely small size of the well-dispersed Pd NPs on the surface surrounded by the crystalline SnO<sub>2</sub> nanospheres. Moreover, no diffraction peaks of the palladium metal and other impurity phase were observed.

The influence of Pd loading on the microstructure of the SnO<sub>2</sub> nanoparticles was most obvious in the HRTEM image. Fig. 3a–c show the HRTEM images of the Pd-loaded nanospheres at different scales. The SnO<sub>2</sub> nanospheres with diameter in the range of 1 μm (Fig. 3a) were surrounded by thin layers of nanosheets (Fig. 3b). Moreover, the Pd nanoparticle loadings can be clearly seen (Fig. 3c), revealing a high crystallinity of SnO<sub>2</sub> and Pd particles. The interplanar spacing of  $d = 0.334$  nm and  $d = 0.264$  nm corresponded to the {110} and {101} crystal orientation of SnO<sub>2</sub> [JCPDS card, no. 41-1445], respectively, and  $d = 0.224$  nm matched the {111} orientation of Pd [JCPDS card, no. 87-0639]. The loaded Pd nanoparticles have been previously proven to enhance the gas response and selectivity.<sup>25,38–40</sup>



**Fig. 3** HRTEM images of the Pd-loaded SnO<sub>2</sub> nanosphere structure at different scales. Scale bars are 2 μm in (a), 200 nm in (b), and 5 nm in (c).

Herein, based on previous studies, 2% loading was chosen as the optimum doping percentage.<sup>40–49</sup>

Based on the abovementioned analysis, the Pd-loaded SnO<sub>2</sub> nanospheres have hierarchical structures, combining nanospheres, nanosheets and nanoparticles, ranging from 1 μm to 100 nm and 5 nm. Hierarchical structures are ideal for the purpose of gas sensing, which provide high surface area and a stable porous structure.<sup>7</sup>

### 3.2 Gas sensing properties of the Pd-loaded SnO<sub>2</sub> nanosphere microsensors

When SnO<sub>2</sub> was exposed to a reducing gas, such as hydrogen sulfide, physical and chemical absorption occurred, which changed the electronic exchange in materials and the conductivity of SnO<sub>2</sub>. When exposed to H<sub>2</sub>S gas at different concentrations, our micro gas sensors showed a wide response range from 10 ppb to 200 ppm. The typical full range H<sub>2</sub>S gas measurement of our micro sensors is illustrated in Fig. 4. Response at 10 ppb of H<sub>2</sub>S was 2% with a signal-to-noise ratio of about 4, well above the requirement for signal recognition. The gas response increased with an increase in the H<sub>2</sub>S concentration (Fig. 4b red dot) to up to 50 ppm; moreover, the response at 50 ppm was 42.8. Above 50 ppm concentration, the response of the sensors to gas was saturated, and it decreased when the sensors were exposed to a higher concentration of gas due to the poison effect.<sup>50–53</sup> In our corrosion gas environment, poisoning effect is the strong chemisorption of H<sub>2</sub>S on the catalytic sites;



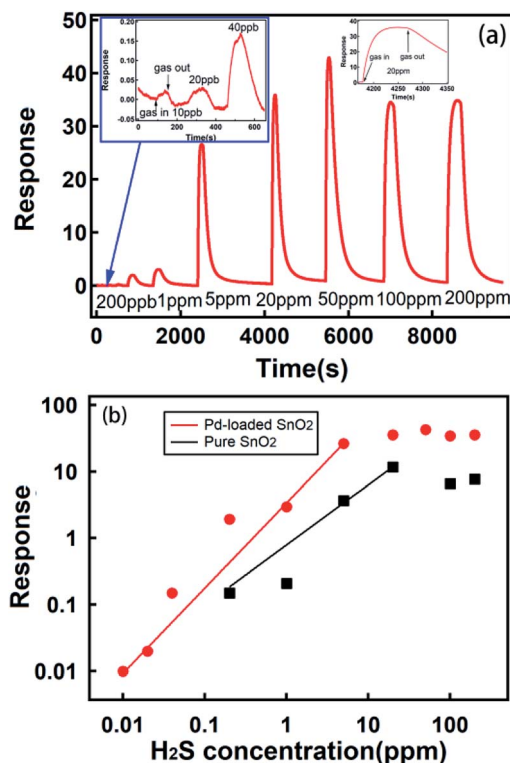


Fig. 4 (a) The response of the Pd-loaded SnO<sub>2</sub> nanosphere sensor towards the detection of H<sub>2</sub>S gas at various concentrations from 10 ppb to 200 ppm at an optimal operation temperature of 200 °C. The inset shows the response of the Pd-loaded SnO<sub>2</sub> nanosphere sensor towards the detection of H<sub>2</sub>S gas with concentrations from 10 ppb to 40 ppb and 20 ppm at an operation temperature of 200 °C. (b) The response logarithm curves of the Pd-loaded and pure SnO<sub>2</sub> nanosphere sensors to H<sub>2</sub>S gas at various concentrations at an operation temperature of 200 °C.

this accordingly blocks the sites for catalytic reaction, and thus, the sensors lose their ability for sensing. Our micro sensor showed good gas responses up to the highest concentration of 200 ppm tested herein. Moreover, we examined the micro gas sensors with pure SnO<sub>2</sub> nanospheres as the sensing materials. The result is shown in Fig. 4b (black dot).

These sensors show a credible gas response up to 200 ppb, and their observed response to gas exposure is 3 to 14 times lower than that for Pd-loaded samples in the test range. Our concentration-dependent data can be seen to follow a power law relation,<sup>54</sup> which is used to describe the sensing characteristics of SnO<sub>2</sub> sensors and can be written as follows:

$$S = kC^\alpha$$

where  $C$  is the concentration and  $k$  is the response coefficient. We plotted response vs. concentration in a log-log plot in Fig. 4b. For the Pd-loaded SnO<sub>2</sub> samples,  $k = 3.4 \text{ ppm}^{-1}$  and  $\alpha = 1.3$ , whereas for the pure SnO<sub>2</sub> samples,  $k = 0.79 \text{ ppm}^{-1}$  and  $\alpha = 0.9$ .

Based on these analyses, it can be concluded that a micro gas sensor based on Pd-loaded SnO<sub>2</sub> nanospheres has a credible gas detection ability down to 10 ppb (with a good signal-to-noise ratio of 4) and 4 orders of magnitude concentration detection

ranges (up to 200 ppm). Its gas response and detection limit was much better than that of pure SnO<sub>2</sub> nanosphere sensor. Response of the pure SnO<sub>2</sub> nanosphere obviously increased after it was loaded with Pd; this could be attributed to the formation of hierarchical structures. Moreover, the Pd nanoparticle loading increased the rate of oxygen dissolution, and the Pd nanoparticles played the role of a catalyst. We also observed that a high concentration of grain boundaries (Fig. 3c) would play an important role in enhanced gas sensing.<sup>7</sup>

Indeed, it is hard to obtain a gas sensor with both an ultra-sensitive gas detection ability and a large detection range. To the best of our knowledge, four orders of magnitude dynamic ranges for H<sub>2</sub>S sensing are unprecedented. We attribute the combination of these two merits in one micro gas sensor to the fact that we created hierarchical structures on the SnO<sub>2</sub> nanosphere surfaces. Obviously, nanosheets of up to 10 nm (Fig. 3c) contacting each other (Fig. 3b) were responsible for an ultra-sensitive response. The nanometer-sized sensing materials have shown superior detecting ability down to sub-ppb level in the past.<sup>55–59</sup> Moreover, large nanospheres of up to 2 μm size possibly accounted for a high concentration (100 ppm) detection, which was the case for our pure SnO<sub>2</sub> nanosphere sensors (Fig. 4b).

The gas sensing ability depends on the physical and chemical absorption properties of a gas, which strongly depend on temperature. We investigated the optimal working temperature of the Pd-loaded and pure SnO<sub>2</sub> nanosphere gas sensor. The experimental conditions, as shown in Fig. 5, are as follows: environmental temperature of 25 °C ± 5 °C and humidity around 30% ± 5% with 1 ppm as the test concentration of H<sub>2</sub>S. For comparison, the pure SnO<sub>2</sub> nanosphere and Pd-loaded SnO<sub>2</sub> nanosphere micro gas sensors were simultaneously tested in 1 ppm H<sub>2</sub>S at a series of temperatures. We changed the test temperature from 150 to 350 °C with a 50 °C integral (Fig. 5). The Pd-loaded SnO<sub>2</sub> nanosphere micro gas sensor and pure SnO<sub>2</sub> nanosphere micro gas sensor were fabricated using the same method listed. Compared with the pure SnO<sub>2</sub> nanosphere sensors, the Pd-loaded SnO<sub>2</sub> nanosphere sensors showed a large temperature dependence. They provided highest responses at a temperature of 150 °C.

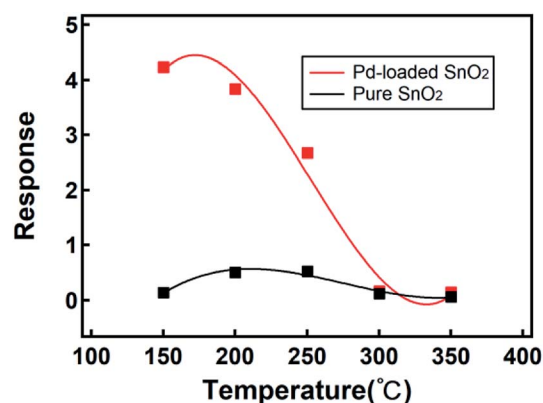


Fig. 5 The response of Pd-loaded (red) and pure (black) SnO<sub>2</sub> nanosphere sensors to 1 ppm H<sub>2</sub>S at different working temperatures.



For the pure SnO<sub>2</sub> samples, the highest responses appeared at 200 °C (Fig. 5). A lower working temperature indicated a lower power consumption rate, which was crucial for micro gas sensors in portable devices. Moreover, a lower working temperature indicated a more stable structure and repeatability of sensors. The response difference between the Pd-loaded samples and the pure sample at 150 °C is 30. As the working temperature increased, the response difference between the two types of sensors decreased, and finally, above 300 °C, their gas sensitivities were at the same level. If the response enhancement is lost above 300 °C, small features in the hierarchical Pd-loaded SnO<sub>2</sub> nanostructures and their advantages at a high temperature are lost; although the exact mechanism requires further investigation, some studies have indicated that a higher carrier concentration in nanosheets at a high temperature can be a reason for the decrease in gas response.<sup>60</sup>

Selectivity is an important index for the gas sensing properties. Hence, the sensor should have a high selectivity for its application. Fig. 6a shows the response of the Pd-loaded and pure SnO<sub>2</sub> to seven gases, *i.e.*, CO, NH<sub>3</sub>, CH<sub>4</sub>, toluene, ethanol, and isopropanol at a concentration of 5000 ppm and H<sub>2</sub>S at 20 ppm at 200 °C. Note that the sensor exhibits highest response to H<sub>2</sub>S and lower responses to other gases. After Pd loading on the SnO<sub>2</sub> surface, the response to the gases increased more than ten times of that expected for NH<sub>3</sub> and CH<sub>4</sub>. In particular, the sensor was insensitive to CH<sub>4</sub>. Moreover, the experimental results indicate that the Pd-loaded SnO<sub>2</sub> nanosphere sensor shows a high selectivity for the detection of H<sub>2</sub>S gas and can distinguish a small amount of H<sub>2</sub>S among 5000 ppm of the interfering gases; this makes the proposed sensor promising for monitoring the extremely dilute leakage of H<sub>2</sub>S gas. The response and recovery times are two significant indices in assessing the gas sensing performance of sensors, which are also related to the detection speed of the sensor. The response and recovery time is defined as the time to reach 90% of the maximum sensing response when the target gas is injected into the test chamber. Similarly, the time for the maximum sensing response decreased to 10% upon air purging.<sup>76</sup> Fig. 6b and c show the response and recovery times of the sensor based on the Pd-loaded SnO<sub>2</sub> nanosphere thin film upon exposure to 20 ppm H<sub>2</sub>S and 5000 ppm of other interfering gases at the working temperature of about 200 °C. It is obvious that for most test gases (except toluene), the sensor recovery time is slow as compared to the response time. A long recovery time at a low working temperature can be due to the sluggish serial reactions referring to the adsorption, dissociation, and ionization of oxygen on the surface.<sup>61</sup> After Pd loading, the response time was reduced from 44–371 s to 15–97 s and the recovery time was reduced from 130–370 s to 80–300 s for the interfering gases at 5000 ppm and H<sub>2</sub>S at 200 °C. Therefore, the increase in the response speed caused by Pd loading can be explained by the promotion of the oxidation reaction between H<sub>2</sub>S and the negatively charged surface oxygen because of the Pd catalyst.<sup>77</sup> In general, the Pd-loaded SnO<sub>2</sub> nanosphere gas sensors show wonderful selectivity and response and recovery speed for the interfering and target gases; thus, the proposed sensor is helpful in detecting the extremely attenuate leakage of H<sub>2</sub>S gas.

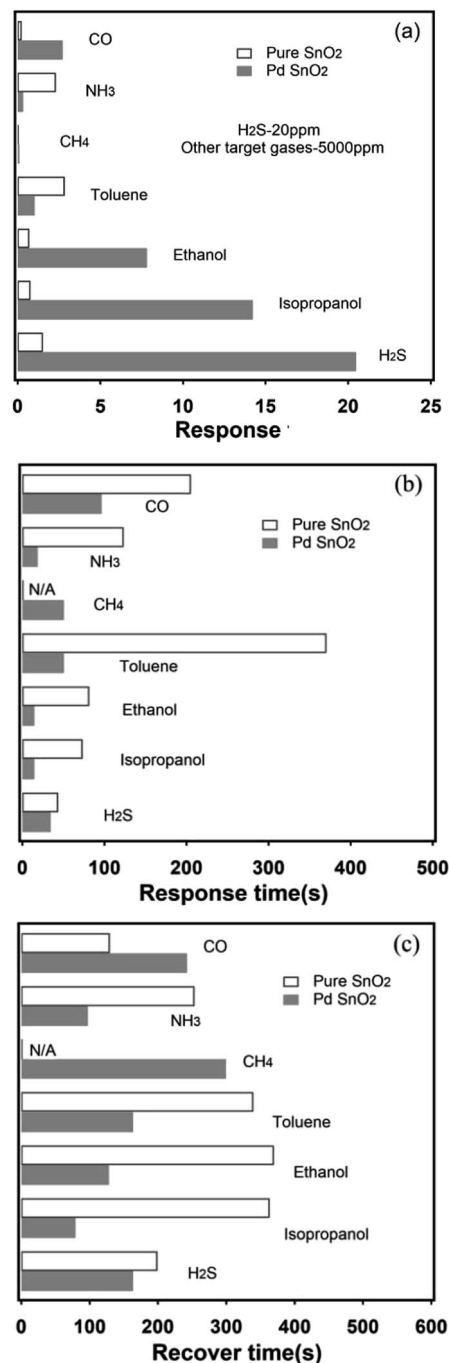


Fig. 6 (a) The sensitivity of Pd-loaded (gray) and pure (white) SnO<sub>2</sub> to interfering gases in a concentration of 5000 ppm and 20 ppm to H<sub>2</sub>S gases at working temperature of 200 °C. (b) Response and (c) recover times of Pd-loaded (gray) and pure (white) SnO<sub>2</sub> upon different gases in a concentration of 5000 ppm and 20 ppm to H<sub>2</sub>S gases at working temperature of 200 °C.

Table 1 presents the comparison of the sensor materials and the concentration range for the H<sub>2</sub>S sensors reported earlier and in this study. It can be clearly seen that the Pd-loaded SnO<sub>2</sub> nanosphere structured materials show a low detectable concentration and a high dynamic range for H<sub>2</sub>S at an optimal working temperature. Compared with the case of other H<sub>2</sub>S sensors reported to date, a low detectable concentration and



**Table 1** A comparison of the detectable concentration and dynamic range at an optimal temperature for the present sensors reported in the literature

Sensor materials	Concentration range	Dynamic range	Temperature	References
SnO <sub>2</sub> /ZnO heteronanostructures	10 ppb	10 <sup>3</sup>	100 °C	9
Cu <sub>x</sub> O-doped SnO <sub>2</sub> film	500 ppb	10 <sup>1</sup>	Room temperature	61
CuO-doped SnO <sub>2</sub>	100	10 <sup>1</sup>	200 °C	62
SnO <sub>2</sub>	1 ppm	10 <sup>1</sup>	200 °C	63
Pt-WO <sub>3</sub> nanotube	150 ppb	10 <sup>1</sup>	450 °C	64
ZnO film	1 ppm	10 <sup>0</sup>	450 °C	65
ZnFe <sub>2</sub> O <sub>4</sub> nanofiber	100 ppb	10 <sup>1</sup>	350 °C	66
Carbon nanotube	5 ppb	10 <sup>3</sup>	Room temperature	67
NiO nanosheet	25 ppm	10 <sup>2</sup>	350 °C	68
Ag-SnO <sub>2</sub> film	1 ppm	10 <sup>1</sup>	200 °C	69
Zn <sub>2</sub> SnO <sub>4</sub> lamellar micro-spheres	50 ppb	10 <sup>2</sup>	170 °C	70
Au nanostars/ZnO mesocrystal	5 ppb	10 <sup>3</sup>	100 °C	71
ZnO nanowires	50 ppb	10 <sup>0</sup>	150 °C	72
K <sub>2</sub> W <sub>4</sub> O <sub>13</sub> nanowires	300 ppb	10 <sup>2</sup>	300 °C	73
Sb-doped SnO <sub>2</sub> nanoribbon	100 ppb	10 <sup>3</sup>	25 °C	74
Mo-doped ZnO nanowires	200 ppb	10 <sup>1</sup>	300 °C	75
Pd-loaded SnO <sub>2</sub>	10 ppb	10 <sup>4</sup>	150 °C	This work <sup>a</sup>

<sup>a</sup> Please see the ESI.

high dynamic range at a low operation temperature have been accomplished in this study.

To test the repeatability and reproducibility, we investigated more than 20 Pd-loaded SnO<sub>2</sub> sensors for a week. The results of the 9 sensors are exhibited in the ESI.† The performance was similar for different devices. Fig. 3 of the ESI† shows that a response to 1 ppm of H<sub>2</sub>S for different devices varies between 3 and 15. A similar response is noticed for concentration (please refer to Fig. 1 of the ESI†) and aging also (please refer to Fig. 3 of the ESI†); however, stability is still not ideal. For ultra-sensitive micro sensors, many factors would contribute to damage the repeatability. We are working on illustrating some of the important factors. The number of active sites and the point of contact play a decisive role, and the details will be described in the next study.

## 4. Conclusions

In summary, micro H<sub>2</sub>S gas sensors based on Pd-loaded SnO<sub>2</sub> hierarchical nanospheres were achieved using a simple hydrothermal method. Structural analysis shows a hierarchical structure with nanospheres and nanosheets, loaded with Pd nanoparticles. These micro sensors are proven to have an ultra-sensitive ppb level (10 ppb) H<sub>2</sub>S detection ability and wide detection range (up to hundreds of ppm) at the same time. The Pd-loaded SnO<sub>2</sub> nanosphere micro-chips work best at low temperatures (150 °C); this is crucial for low-power consumption applications. Our Pd-loaded SnO<sub>2</sub> nanosphere micro gas sensors are cost-effective, easy to make, simple to operate and ultra-sensitive for the detection of H<sub>2</sub>S with a wide detection range. The fabrication method presented herein is simple, renewable and operable and thus may be extended to synthesize other types of metal oxide-based semiconductor micro sensors for applications in various fields.

## Conflicts of interest

The authors declare no competing financial interests.

## Acknowledgements

This research was supported by the National Basic Research Program of China (2014CB920904), the National Natural Science Foundation of China (NSFC, Grant No. 21601133, 61701543), the Strategic Priority Research Program of Chinese Academy of Sciences (Grant No. XDB30000000), and the Strategic Priority Research Program of Chinese Academy of Sciences (Grant No. XDB07030100), Sinopec Innovation Scheme (A-381).

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